Patent Attorney's Docket No. <u>030681-366</u>

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

| In re Patent Application of  | )<br>}                       |
|--|------------------------------|
| Kyo-yeol LEE   | ) Group Art Unit: Unassigned |
| Application No.: New Application   | ) Examiner: Unassigned       |
| Filed: Herewith  | )<br>)                       |
| For: METHOD FOR FABRICATING GROUP III-V COMPOUND SEMICONDUCTOR SUBSTRATE | )<br>)<br>)                  |

## PRELIMINARY AMENDMENT

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

Prior to examination on the merits, kindly amend the above-captioned application as follows:

## IN THE SPECIFICATION:

Kindly add the following paragraph on page 1, after the title of the invention and before the "Background of the Invention," —Priority is claimed to Patent Application

Number 2001-11153 filed in the Republic of Korea on March 5, 2001 herein incorporated by reference.—